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INFORMATION DISCLOSURE STATEMENT BY APPLICANT

Complete if Known

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|------------------------|-----------------|
| Application Number | Unassigned |
| Filing Date | March 11, 2004 |
| First Named Inventor | KAWAHARA et al. |
| Group Art Unit | Unassigned |
| Examiner Name | Unassigned |
| Attorney Docket Number | 403001 |

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| Sheet | 1 | of | 1 |
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| OTHER - NON PATENT LITERATURE DOCUMENTS | | | | |
|-----------------------------------------|----------|-----------------------------------------------------------------------------------------------------------------------------------------------------------------------------------------------------------------------------------------------------------------------|-------------|------|
| Examiner Initials | Doc. No. | Include name of the author (in CAPITAL LETTERS), title of the article (when appropriate), title of the item (book, magazine, journal, serial, symposium, catalog, etc.), date, page(s), volume-issue number (s), publisher, city and/or country where published. | Translation | |
| | | | Yes | No** |
| CL | A 2 | BLIN, et al., "Study of the initial steps of ALD HfO ₂ growth on SiO ₂ ", Atomic Layer Deposition (ALD) 2002, American Vacuum Society Topical Conference, August 19-21, 2002, Hanyang Institute of Technology, Hanyang University, Seoul, Korea | | |
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Johnny Lee

10 / 12 / 05

- * A concise statement of relevance is being submitted in lieu of a translation. 37 CFR 1.98(a)(3).
- + An English-language equivalent/patent, or an English-language abstract, or an English-language version of the search report or action by a foreign patent office in a counterpart foreign application indicating the degree of relevance found by the foreign office is being submitted in lieu of a concise explanation of relevance under 37 CFR 1.98(a)(3).